

Trion Technology introduces new photoresist stripper

Founded in 1989, Trion Technology Inc of Clearwater, FL, USA supplies a variety of plasma etch and deposition equipment for the manufacturing of compound semi-conductors, MEMS, and optoelectronics.

Recently, the company introduced a new microwave photoresist stripping system. The Apollo is a compact, inexpensive and versatile system, which can handle 100-300mm wafers, says the company. It has an etch rate of 6um /min. By employing both microwave and RF bias power as needed, difficult to remove layers of resist can be removed at low temperatures. The system also incorporates the SST-Lightning microwave source, which according to Trion is totally free from typical microwave tuning problems.

Contact: info@triontech.com

Visit: <http://www.triontech.com>

